water;

an abrasive;

a roll-off reducing agent comprising one or more compounds selected from the group consisting of carboxylic acids having 2 to 20 carbon atoms having either OH group or groups or SH group or groups, monocarboxylic acids having 1 to 20 carbon atoms, and dicarboxylic acids having 2 to 3 carbon atoms, and salts thereof; and an intermediate alumina.

Please add the following claims:

Claim 14. (New) A process for producing a substrate comprising a step of polishing a substrate to be polished with a polishing composition comprising:

VY

- (A) one or more compounds selected from carboxylic acids having 2 to 20 carbon atoms having either OH group or groups or SH group or groups, monocarboxylic acids having 1 to 20 carbon atoms, and literioxylic acids having 2 to 5 carbon atoms, and salts thereof;
- (B) one or more compounds selected from polycarboxylic acids having a or more carbon atoms and having neither OH or up or groups

(C) one or more compounds selected from an intermediate alumina and an alumina sol;

an abrasive; and
water.

Claim 15. (New) The process of claim 14, wherein the intermediate alumina and the alumina sol in Compounds (C) have a specific surface area of from 30 to 300 m²/g and an average particle size of 0.01 to 5 μm .

Claim 16. (New) The process of claim 14, wherein the intermediate alumina is prepared from aluminum hydroxide and/or alumina sol, each having a specific surface area of $10 \text{ m}^2/\text{g}$ or more and a content of an alkali metal and a content of an alkaline earth metal of 0.1° by weight or less.

Claim 17. (New) A process for producing a substrate comprising a step of p diching a substrate to be polished with a polishing composition comprising:

(A) one or more compounds selected from carboxylic acids having 2 to .0 Tarks: atoms having either CH group or groups or CH

11.010 17 41.1

KS.

(B) one or more compounds selected from polycarboxylic acids having 4 or more carbon atoms and having neither OH group or groups nor SH group or groups, aminopolycarboxylic acids, amino acids and salts thereof;

an abrasive; and water.

Claim 18. (New) The process of claim 17, wherein one or more compounds of Compounds (A) are selected from carboxylic acids having 2 to 20 carbon atoms having either OH group or groups or SH group or groups, and dicarboxylic acids having 2 to 3 carbon atoms, and salts thereof, and wherein one or more compounds of Compounds (B) are selected from polycarboxylic acids having 4 or more carbon atoms and having neither CH group or groups nor SH group or groups, aminopolycarboxylic acids, and salts thereof.

Claim 19. (New) The process of claim 17, wherein one or more compounds at Empounds (A) are relected from exalid a (i), malenia acid, glycolic acid, lactic acid, malic acid, glycoxylic acid, tartaric acid, citric acid, slucenic acid, and salts thereof, and wherein one or more compounds of Compounds (B) are selected from succinic acid, maleic acid, temaric acid, citric acid,

and the state of t

Proposition of